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Shimoda et al.

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(54) **ORGANIC EL DISPLAY AND MANUFACTURING METHOD THEREOF, MULTI-HOLED SUBSTRATE, ELECTRO-OPTIC DEVICE AND MANUFACTURING METHOD THEREOF, AND ELECTRONIC DEVICE**

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(30) **Foreign Application Priority Data**

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Jul. 3, 2001 (JP) P2001-201710

(51) Int. Cl.⁷ **H01J 1/62; H01J 63/04**

(52) U.S. Cl. **313/504**

(58) Field of Search 313/504, 506, 313/500; 315/169.3, 45, 76, 55; 428/917

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5,824,186 A 10/1998 Smith et al.
5,904,545 A 5/1999 Smith et al.
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(57) **ABSTRACT**

An object is to efficiently manufacture an organic EL display which uses microstructures. Microstructures are inlaid in a plurality of concavities in the surface of a nonconductive multi-holed substrate. On the multi-holed substrate, besides the concavities there is formed a plurality of through holes. The surface of the multi-holed substrate is covered with a nonconductive protective film. A transparent substrate on the surface of which is formed beforehand a transparent electrode layer is prepared, and the transparent substrate is attached to the rear face side of the multi-holed substrate. Contact holes are formed after which a luminous layer is formed inside the through holes by an ink jet method. The surface of the multi-holed substrate including the inside of the contact holes is covered with a metallic layer such as aluminum, and the metallic layer is then patterned, and negative electrodes and wiring are formed.

5 Claims, 5 Drawing Sheets

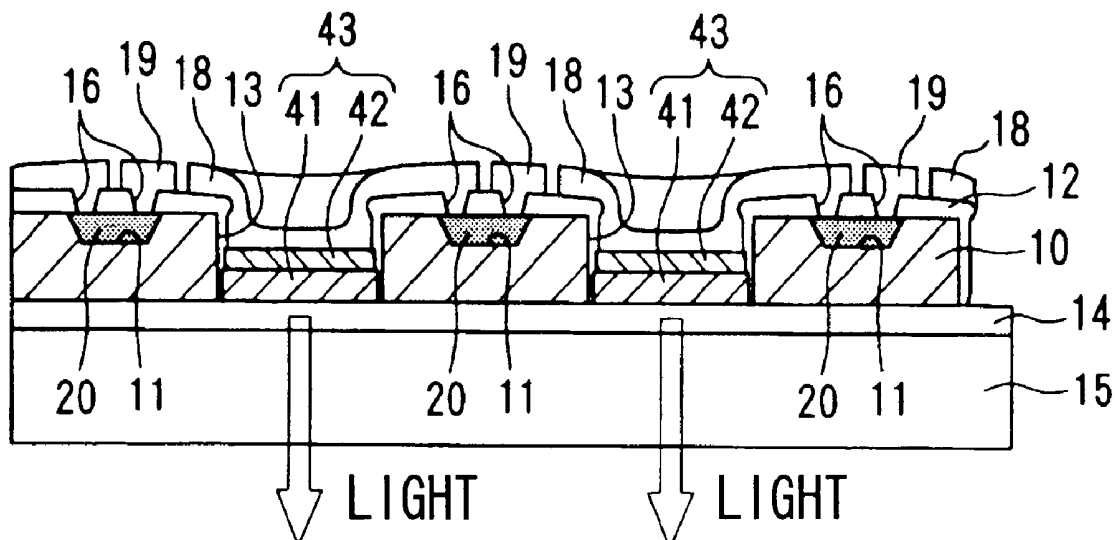


FIG. 1A

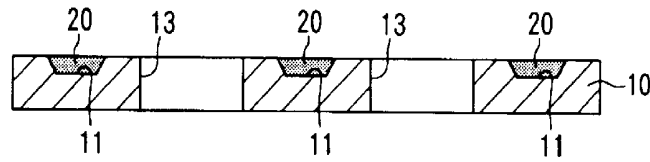


FIG. 1B

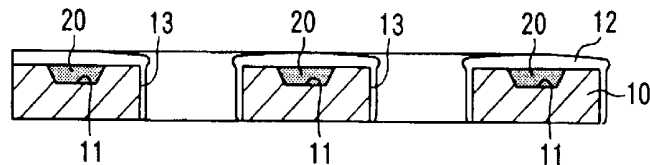


FIG. 1C

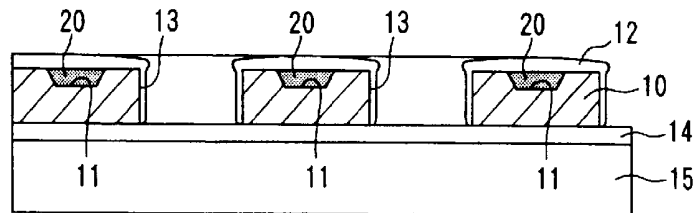


FIG. 1D

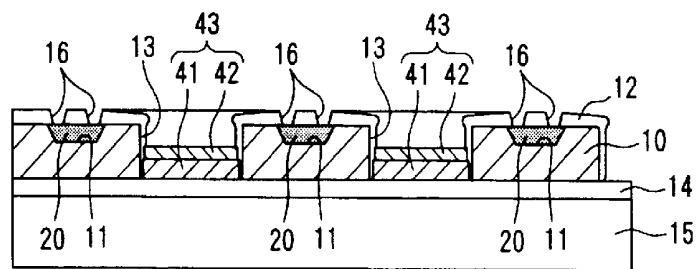


FIG. 1E

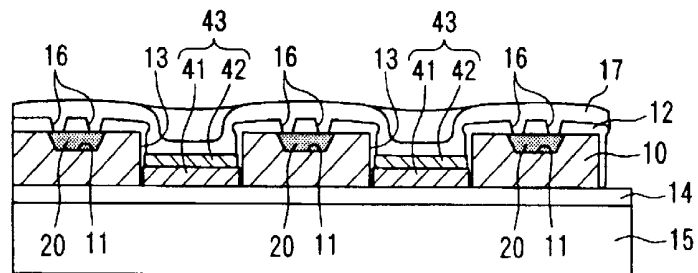


FIG. 1F

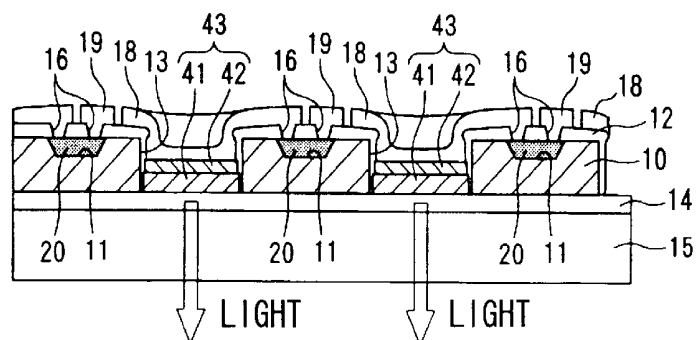


FIG. 2

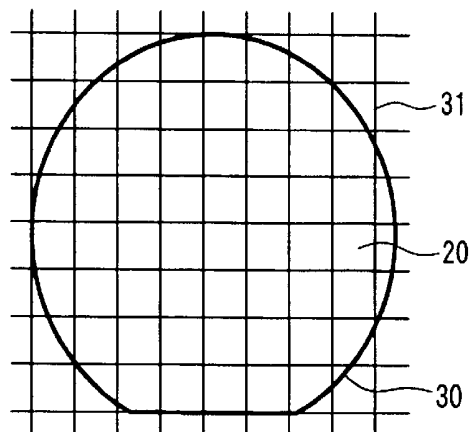


FIG. 3

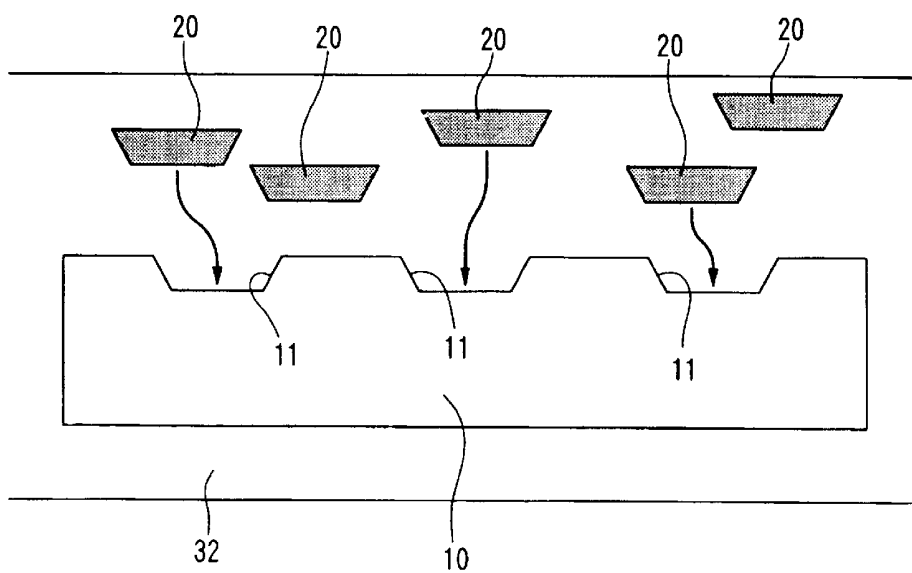


FIG. 4

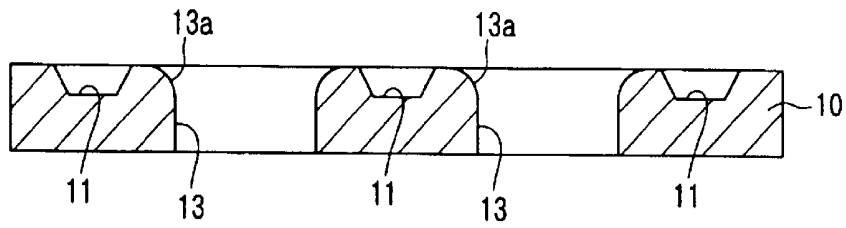


FIG. 5

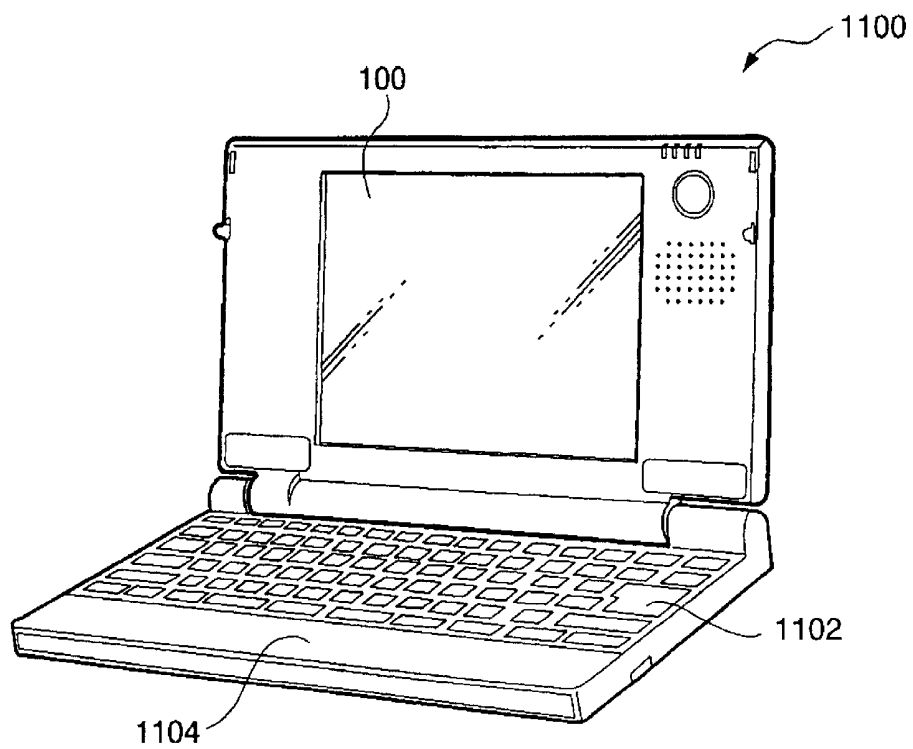


FIG. 6

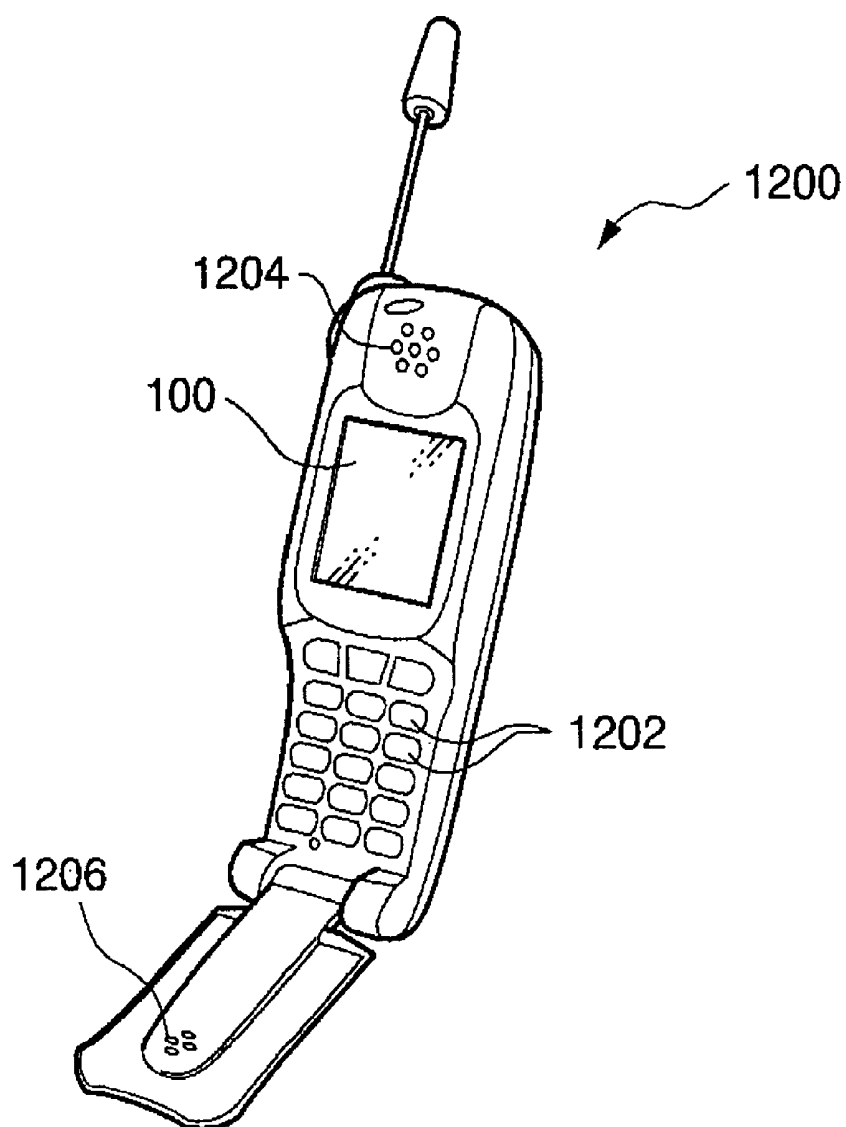
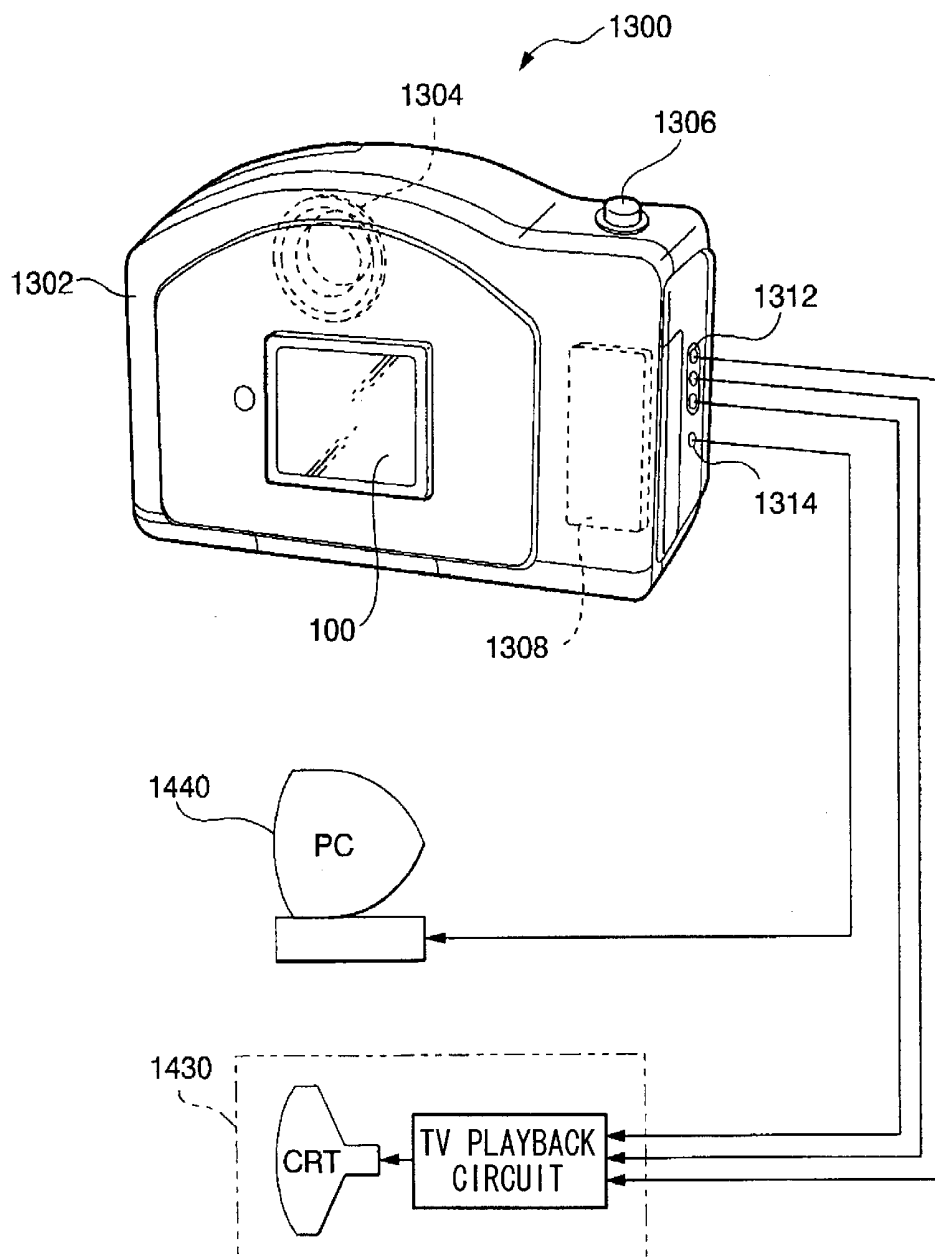


FIG. 7



**ORGANIC EL DISPLAY AND
MANUFACTURING METHOD THEREOF,
MULTI-HOLED SUBSTRATE, ELECTRO-
OPTIC DEVICE AND MANUFACTURING
METHOD THEREOF, AND ELECTRONIC
DEVICE**

BACKGROUND OF THE INVENTION

1. Field of the Invention

The present invention relates to an organic electroluminescence (hereunder EL for short) display and a manufacturing method thereof, and to a multi-holed substrate ideally used therein. In particular the invention is one where, in a display incorporating microstructures made with drive circuits for organic EL elements, and a manufacturing method thereof, the organic EL display can be manufactured extremely efficiently.

2. Description of Related Art

Heretofore, there is a method of manufacturing an electronic device using microstructures made with electronic circuit elements (refer for example to U.S. Pat. Nos. 5,904,545, 5,824,186, 5,783,856, and 5,545,291).

That is, there is a manufacturing method which uses microstructures, and which enjoys for example the advantage that even with a configuration where a plurality of electronic circuits are scattered over a substrate of an electronic device, the semiconductor material need not be wasted.

Therefore, the present inventors and others, as a result of earnest research, have completed a manufacturing method for obtaining an organic EL display involving firstly, making a drive circuit for an organic EL element within a microstructure and arranging this on a transparent substrate, and then performing in sequence; a wiring forming step, a transparent electrode forming step, a luminous layer forming step and a negative electrode forming step. However while undoubtedly it has been shown that the organic EL display can be manufactured while enjoying the advantages from such a microstructure, in practice in order to mass produce the organic EL display with a profit base, further improvement is desired.

BRIEF SUMMARY OF THE INVENTION

The present invention has resulted due to such requirements, with the object of providing a construction and manufacturing method for an organic EL display whereby an organic EL display can be manufactured extremely efficiently.

In order to achieve the above object, a first aspect of the present invention is a display which uses an organic EL element as pixels, wherein a nonconductive multi-holed substrate having; a plurality of concavities in which are inlaid a plurality of microstructures made with drive circuits for the organic EL element, and through holes which pass through between front and rear faces at formation positions of the pixels is used, and a luminous layer containing an organic EL layer is formed inside the through holes of the multi-holed substrate.

A second aspect of the present invention is that in the organic EL display being the first aspect, chamfering is given to a surface side edge portion of the through holes of the multi-holed substrate.

In order to achieve the above object, a third aspect of the present invention is a manufacturing method for a display

which uses an organic EL element as pixels, involving using a nonconductive multi-holed substrate having; a plurality of concavities in which are inlaid a plurality of microstructures made with drive circuits for the organic EL element, and through holes which pass through between front and rear faces at formation positions of the pixels, and forming a luminous layer containing an organic EL layer inside the through holes of the multi-holed substrate.

In order to achieve the above object, a fourth aspect of the present invention is a manufacturing method for a display which uses an organic EL element as pixels, involving using a nonconductive multi-holed substrate having; a plurality of concavities in which are inlaid a plurality of microstructures made with drive circuits for the organic EL element, and through holes which pass through between front and rear faces at formation positions of the pixels, and providing: a microstructure inlaying step for inlaying the microstructures in the concavities of the multi-holed substrate and then covering with a nonconductive protective film; a transparent electrode layer and transparent substrate forming step for providing in sequence a transparent electrode layer and a nonconductive transparent substrate on a rear face side of the multi-holed substrate; a luminous layer forming step for forming a luminous layer containing an organic EL layer inside the through holes of the multi-holed substrate provided with the transparent electrode layer; and a negative electrode and wiring forming step for forming a negative electrode and wiring on a surface of the multi-holed substrate formed with the luminous layer.

A fifth aspect of the present invention is that in the manufacturing method for an organic EL display according to the third or fourth aspects, chamfering is given to a surface side edge of the through holes of the multi-holed substrate.

Furthermore, a sixth aspect of the present invention is that in the manufacturing method for an EL display of the fourth or fifth aspects, in the transparent electrode layer and transparent substrate forming step, the transparent electrode layer is provided beforehand on the surface of the transparent substrate, and the transparent substrate is attached to a rear face side of the multi-holed substrate with the transparent electrode layer on an inside.

Furthermore, a seventh aspect of the present invention is that in the manufacturing method for an organic EL display according to any one of the fourth through sixth aspects, in the luminous layer forming step, the luminous layer is formed using an ink jet method.

Moreover, an eighth aspect of the present invention is that in the manufacturing method for an organic EL display according to any one of the fourth through seventh aspects, in the negative electrode and wiring forming step, the negative electrode and the wiring are formed separately.

On the other hand, a ninth aspect of the present invention is that in the manufacturing method for an organic EL display according to any one of the fourth through seventh aspects, in the negative electrode and wiring forming step, a surface of the multi-holed substrate on which the luminous layer is formed is covered with a metallic layer, and the metallic layer is patterned to form the negative electrode and the wiring at the same time.

A tenth aspect of the present invention is that in the manufacturing method for an organic EL display according to the ninth aspect, after the transparent electrode layer and transparent substrate forming step, and before the luminous layer forming step, there is provided a contact hole forming step for forming on the protective film contact holes which

pass to electrode pads provided on the surface of the microstructures.

An eleventh aspect of the present invention is that in the manufacturing method for an organic EL display according to any one of the fourth through tenth aspects, in the microstructure inlaying step, the microstructure is inlaid in the concavity while in a liquid.

On the other hand, a twelfth aspect of the present invention is a multi-holed substrate used in a display which uses an organic EL element as pixels, comprising a material with nonconductivity, and wherein a plurality of concavities in which are inlaid a plurality of microstructures made with drive circuits for the organic EL element is provided on a surface, and through holes which pass through between front and rear faces are provided at formation positions of the pixels.

A thirteenth aspect of the present invention is that in the multi-holed substrate being the twelfth aspect, chamfering is given to a surface side edge portion of the through holes of the multi-holed substrate.

A fourteenth aspect of the present invention is an electro-optic device which uses a luminous element as pixels, wherein a multi-holed substrate having; a plurality of concavities in which are inlaid a plurality of microstructures made with drive circuits for the luminous element, and through holes which pass through between front and rear faces at formation positions of the pixels is used, and a luminous layer is formed inside the through holes of the multi-holed substrate.

A fifteenth aspect of the present invention is a manufacturing method for an electro-optic device which uses a luminous element as pixels, involving using a multi-holed substrate having; a plurality of concavities in which are inlaid a plurality of microstructures made with drive circuits for the luminous element, and through holes which pass through between front and rear faces at formation positions of the pixels, and forming a luminous layer inside the through holes of the multi-holed substrate.

A sixteenth aspect of the present invention is that the electro-optic device of the fourteenth aspect is provided.

According to the organic EL display and manufacturing method thereof according to the present invention, since a multi-holed substrate formed with through holes is used, the manufacturing process is simplified, with the effect that a reduction in manufacturing cost is possible.

Moreover, with the multi-holed substrate according to the present invention, an ideal multi-holed substrate is provided for the organic EL display and the manufacturing method thereof according to the present invention.

BRIEF DESCRIPTION OF THE SEVERAL VIEWS OF THE DRAWINGS

FIG. 1A to FIG. 1F are cross-sectional views showing manufacturing steps of a first embodiment.

FIG. 2 is an explanatory diagram of a manufacturing method of a microstructure.

FIG. 3 is an explanatory diagram of a process for capturing microstructures in a transparent substrate.

FIG. 4 is a cross-sectional view showing the construction of a multi-holed substrate of a second embodiment.

FIG. 5 is a perspective view illustrating a construction of a personal computer being an example of an electronic device of the present invention.

FIG. 6 is a perspective view illustrating a construction of a portable telephone being an example of an electronic device.

FIG. 7 is a perspective view illustrating a construction of a rear face side of a digital still camera being an example of an electronic device.

DETAILED DESCRIPTION OF THE INVENTION

Hereunder is a description of embodiments of the present invention based on the drawings.

FIG. 1A to FIG. 1F, FIG. 2 and FIG. 3 are diagrams illustrating a first embodiment of the present invention, FIG. 1A to FIG. 1F being cross-sectional views showing manufacturing steps of an organic EL display.

That is, as shown in FIG. 1A, on the surface of a nonconductive multi-holed substrate **10** comprising a synthetic resin or the like of a thickness of around 100 μm , a plurality of microstructures **20** are inlaid in proximity to locations where pixels are subsequently formed. Inside the microstructures **20** is formed a plurality of electrode pads (not shown in the figure) for electrical connection with an external power supply or the like.

The manufacturing method itself for the microstructures **20**, and the method of inlaying these in the multi-holed substrate **10** is detailed in U.S. Pat. Nos. 5,904,545, 5,824, 186, 5,783,856, and 5,545,291, and is described briefly here. At first, as shown in FIG. 2, drive circuits comprising transistors, wiring and so forth are multiply formed on a semiconductor wafer **30** using a known photolithography process. Then the rear face is polished to give a predetermined thickness, after which the semiconductor wafer **30** is separated into individual microstructures **20** by dividing up along dividing lines **31**.

Next, as shown in FIG. 3, a multi-holed substrate **10** with concavities **11** formed by a press or the like to a shape capable of engagement with the rear face shape of the microstructures **20** is placed in a liquid **32** with an upper surface thereof directed upwards, and a plurality of microstructures **20** are moved in the liquid **32** so as to follow along the upper surface of the multi-holed substrate **10**, to thereby capture the microstructures **20** in the concavities **11**. Once capture of the microstructures **20** is complete, in order to prevent the microstructures **20** from coming out, then as shown in FIG. 1B, the surface of the multi-holed substrate **10** is covered with a nonconductive protective film **12** (microstructure inlaying step).

In the multi-holed substrate **10**, besides the concavities **11** there is formed a plurality of through holes **13** passing through the front and rear surfaces thereof. The formation position of the through holes **13** is the formation position of the pixels of the organic EL display, and the planar shape thereof becomes a shape which is one size larger than the desired pixel. The protective film **12** is also be adhered to the inside of the through holes **13**.

Next, as shown in FIG. 1C a glass or synthetic resin transparent substrate **15** on the surface of which is formed beforehand a transparent electrode (ITO electrode) layer **14** is prepared, and the transparent substrate **15** is attached to the rear face side of the multi-holed substrate **10** so that the transparent electrode layer **14** is on the inside (transparent electrode and transparent substrate forming step). By so doing, the transparent electrode layer **14** faces the bottom part of the through holes **13**.

Then, as shown in FIG. 1D, the protective film **12** is partially opened by a known photolithography process to form contact holes **16** passing to electrode pads of the microstructures **20** (contact hole forming step). Moreover, after subjecting to a required water-repellent process and

hydrophilic process, an operation for spreading a liquid state material as a pixel forming region by an ink jet method from above the through holes **13** towards the bottom, and then drying this is repeated to thereby form a luminous layer **43** comprising a positive hole injection layer **41** and an organic EL layer **42** inside the through holes **13** (luminous layer forming step). Even though the material is selectively spread on the through holes **13** by the ink jet method, the point that the print positional accuracy is extremely high with current ink jet methods, and the point that outflow of the material is prevented by the through hole **13** itself, ensures that the formation position of the luminous layer **43** can be controlled to a high accuracy.

Then, as shown in FIG. 1E, the surface of the multi-holed substrate **10** including the inside of the contact holes **16** is covered with a metallic layer **17** such as aluminum by an evaporation method or a sputtering technique. Furthermore, the metallic layer **17** is patterned by a known photolithography process, and as shown in FIG. 1F, negative electrodes **18** and wiring **19** are formed at the same time (negative electrode and wiring forming step).

Accordingly, supply of current to the luminous layer **43** becomes possible, and the light emitted therefrom, as shown in FIG. 1F, passes through the transparent electrode layer **14** and the transparent substrate **15** and is shone to the outside from the rear face side of the transparent substrate **15**. Therefore, the rear face side of the transparent substrate **15** becomes the screen of the organic EL display.

In this manner, in the present embodiment, an organic EL display which uses the microstructures **20** can be manufactured.

Moreover, in the present embodiment, since the organic EL display is manufactured using the multi-holed substrate **10** formed with the through holes **13**, then compared to the conventional manufacturing process for the organic EL display where the luminous layer is formed while creating banks or the like on the transparent substrate, the manufacturing process is simplified, with the effect that a reduction in manufacturing cost is possible.

Furthermore, according to the present embodiment, since there is no wiring or electronic circuits and the like beneath (on the transparent substrate **15** side) the through holes **13** being the pixel forming region, then as well as improving the numerical aperture of each pixel, this gives an extremely advantageous construction.

In the present embodiment, by forming the negative electrodes **18** and the wiring **19** at the same time, the number of steps is reduced. However forming these at the same time is not essential to the present invention, and these may be formed in separate steps.

FIG. 4 is a diagram illustrating a second embodiment of the present invention, being a cross-sectional view showing the construction of a multi-holed substrate **10**. The shape of the multi-holed substrate **10**, with the exception of the different parts, is the same as for the first embodiment, and a diagram and explanation for the manufacturing method of the organic EL display is omitted.

That is, with the present embodiment, by chamfering the edge portion (angled portion) of the surface side (the side formed with the concavities **11**) of the through holes **13**, a taper portion **13a** is formed at the chamfer. With such a configuration, in the case where construction is performed by steps such as shown in FIG. 1A to FIG. 1F, the possibility of the metallic layer **17** being severed at the angled portion of the through holes **13** can be greatly reduced. Hence there is an advantage such as an increase in yield.

In the above embodiment, the description has been given for an organic EL display as one example of an electro-optic device. However the present invention where microstructures formed with drive circuits are positioned in concavities on a substrate, may, other than the organic EL substrate, also be applied to electro-optic devices of the self luminescent type such as plasma displays.

<Electronic Devices>

Next is a description of several examples where the organic EL display as one example of the abovementioned electro-optic device, is used in specific electronic devices.

<First Example: Mobile Type Computer>

At first is a description of an example for where an organic EL display according to the embodiments is applied to a mobile type personal computer. FIG. 5 is a perspective view illustrating the construction of this personal computer. In the figure, a personal computer **1100** comprises a main frame **1104** incorporating a key board **1102**, and a display unit **1106**. The display unit **1106** has an organic EL display panel **100**.

<Second Example: Portable Telephone>

Next is a description of an example for where an organic EL display is applied to a display section of a mobile telephone. FIG. 6 is a perspective view illustrating the construction of this mobile telephone. In the figure, a mobile telephone **1200** incorporates a plurality of operating buttons **1202** as well as, an earpiece **1204**, a mouth piece **1206** and the abovementioned organic EL display panel **100**.

<Third Example: Digital Still Camera>

Next is a description of a digital still camera which uses an organic EL display in a finder. FIG. 7 is perspective view illustrating the construction of this digital still camera, with connections for external equipment also shown simplified.

In contrast to a normal camera where the film is exposed by an optical image of a photographic subject, with the digital still camera **1300**, the optical image of the photographic subject is photoelectrically converted by an imaging element such as a CCD (charged coupled device) to thereby produce an image signal. Here, the construction is such that the abovementioned organic EL display panel **100** is provided on a back face of a case **1302** of the digital still camera **1300**, and display is performed based on the image signal from the CCD. Therefore the organic EL display panel **100** functions as a finder for displaying the photographic subject. Furthermore, on the viewing side (the rear face side in the figure) of the case **1302** there is provided a light receiving unit **1304** which includes an optical lens and a CCD or the like.

Here, when the photographer has confirmed the subject image displayed on the organic EL display panel **100** and pushes a shutter button **1306**, the image signal from the CCD at that point in time is sent to a memory of a circuit substrate **1308** and stored therein. Furthermore, in this digital still camera **1300**, on the side face of the case **1302** there is provided a video signal output terminal **1312** and an input-output terminal **1314** for data communication. Moreover, as shown in the figure, as required, a television monitor **1430** is connected to the former video signal output terminal **1312**, or a personal computer **1430** is connected to the later data communication input-output terminal **1314**. Furthermore, the construction is such that by a predetermined operation, the imaging signal stored in the memory of the circuit substrate **1308** is output to the television monitor **1430** or the personal computer **1440**.

For the electronic device, in addition to the personal computer of FIG. 5, the mobile telephone of FIG. 6, or the digital still camera of FIG. 7, there can be given devices such

as a liquid crystal display, a view finder type or direct view monitor type video recorder, a car navigation unit, a pager, an electronic notebook, an electronic calculator, a word processor, a work station, a video phone, a POS terminal, a device furnished with a touch panel and so on. Moreover, 5
needless to say for the display section of these various electronic devices, the abovementioned display device can be applied.

What is claimed is:

1. An organic EL display which uses an organic EL 10
element as pixels comprising:

a nonconductive multi-holed substrate having front and rear faces;

a plurality of concavities in said multi-holed substrate;

a plurality of microstructures made with drive circuits for 15
said organic EL element, said plurality of microstructures being inlaid in said plurality of concavities;

through holes in said multi-holed substrate passing 20
through said multi-holed substrate between said front and rear faces, said through holes being located at formation positions where said pixels are used; and

a luminous layer containing an organic EL layer, said 25
luminous layer being inside said through holes of said multi-holed substrate.

2. The organic EL display according to claim 1, wherein a surface side edge portion of said through holes of said multi-holed substrate is chamfered.

3. A multi-holed substrate used in a display which uses an organic EL element as pixels comprising:

a nonconductive material having front and rear faces;

a plurality of concavities in one of said faces of said material;

a plurality of microstructures made with drive circuits for said organic EL element, said plurality of microstructures being inlaid in said plurality of concavities; and

a plurality of through holes in said material which pass through said material between said front and rear faces, said through holes being provided in said material at formation positions of said pixels.

4. The multi-holed substrate according to claim 3, wherein a surface side edge portion of said through holes of said material is chamfered.

5. An electro-optic device which uses a luminous element as pixels comprising:

a multi-holed substrate having front and rear faces;

a plurality of concavities in said multi-holed substrate;

a plurality of microstructures made with drive circuits for said luminous element, said microstructures being inlaid in said concavities;

through holes in said multi-holed substrate which pass through said multi-holed substrate between said front and rear faces, said through holes being located at formation positions where said pixels are used; and

a luminous layer inside said through holes of said multi-holed substrate.

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UNITED STATES PATENT AND TRADEMARK OFFICE
CERTIFICATE OF CORRECTION

PATENT NO. : 6,696,785 B2
DATED : February 24, 2004
INVENTOR(S) : Shimoda et al.

Page 1 of 1

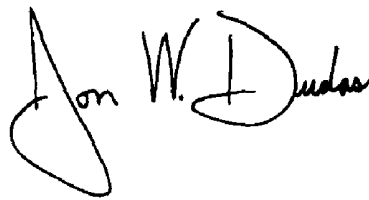
It is certified that error appears in the above-identified patent and that said Letters Patent is hereby corrected as shown below:

Title page.

Item [75], Inventors, **Shimoda** "Nagano-ken" should be -- Fujimi-cho -- **Inoue**
"Nagano" should be -- Chino-shi --

Signed and Sealed this

Thirteenth Day of July, 2004

A handwritten signature in black ink, appearing to read "Jon W. Dudas", is written over a horizontal line.

JON W. DUDAS
Acting Director of the United States Patent and Trademark Office

专利名称(译)	有机EL显示器及其制造方法，多孔基板，电光器件及其制造方法，以及电子器件		
公开(公告)号	US6696785	公开(公告)日	2004-02-24
申请号	US09/900520	申请日	2001-07-06
[标]申请(专利权)人(译)	下田TATSUYA MIYASHITA 悟 井上聪		
申请(专利权)人(译)	下田TATSUYA MIYASHITA 悟 井上聪		
当前申请(专利权)人(译)	京东方科技集团股份有限公司.		
[标]发明人	SHIMODA TATSUYA MIYASHITA SATORU INOUE SATOSHI		
发明人	SHIMODA, TATSUYA MIYASHITA, SATORU INOUE, SATOSHI		
IPC分类号	H05B33/10 H05B33/12 H05B33/02 G09F9/00 G09F9/30 H01L27/32 H01L51/50 H01J1/62 H01J63/04		
CPC分类号	H05B33/10 H05B33/12 H01L51/56 H01L27/3255 H01L2224/95136 H01L2924/15155 H01L2924/15165 H01L2924/15153 H01L2227/323 H01L2224/95146		
审查员(译)	奥谢，桑德拉		
优先权	2000207391 2000-07-07 JP 2001201710 2001-07-03 JP		
其他公开文献	US20020041149A1		
外部链接	Espacenet USPTO		

摘要(译)

一个目的是有效地制造使用微结构的有机EL显示器。微结构镶嵌在非导电多孔基板表面的多个凹面中。在多孔基板上，除了凹陷之外，还形成有多个通孔。多孔基板的表面覆盖有非导电保护膜。预先在其表面上形成透明基板，制备透明电极层，并将透明基板安装在多孔基板的背面侧。形成接触孔，之后通过喷墨方法在通孔内形成发光层。包括接触孔内部的多孔基板的表面覆盖有诸如铝的金属层，然后图案化金属层，并形成负电极和布线。

